

New and existing installations: other rotogravure, flexography, rotary screen printing, lamination and varnishing units	15 - 25	100	25
	> 25	100	20
New and existing installations: rotary screen printing on textiles, paperboard	> 30	100	20

a/ Solvent residue in finished products is not to be considered as part of the fugitive emissions of NMVOCs.

16. Manufacturing of pharmaceutical products:

Table 10. Limit values for NMVOC emissions released from manufacturing of pharmaceutical products

Capacity, technique, further specification	Threshold value for solvent consumption (Mg/year)	Limit value (mg C/Nm ³)	Limit value for fugitive emissions of NMVOCs (% of solvent input)
New installations	> 50	20 ^{a/ b/}	5 ^{b/ d/}
Existing installations	> 50	20 ^{a/ c/}	15 ^{c/ d/}

a/ If techniques are used which allow reuse of recovered solvents, the limit value shall be 150 mg C/Nm³.

b/ A total limit value of 5% of solvent input may be applied instead of using the waste gas concentration limit and the limit value for fugitive emissions of NMVOCs.

c/ A total limit value of 15% of solvent input may be applied instead of using the waste gas concentration limit and the limit value for fugitive emissions of NMVOCs.

d/ The fugitive limit value does not include solvents sold as part of a coatings preparation in a sealed container.